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
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 Applicant: **Research Development Corporation of Japan**
5-2, Nagatacho 2-chome
Chiyoda-ku Tokyo(JP)


 Inventor: **Sugawara, Eishu**
4-10, Kitamaecho Yamada
Sendai-shi Miyagi(JP)

 Inventor: **Nakayama, Taketoshi**
23-33, Kongosawa 1-chome
Sendai-shi Miyagi(JP)

 Inventor: **Masumoto, Tsuyoshi**
8-22, Kamisugi 3-chome
Sendai-shi Miyagi(JP)

 Representative: **Dipl.-Ing. Schwabe, Dr. Dr. Sandmair, Dr. Marx**
Stuntzstrasse 16
D-8000 München 80(DE)

 **Thin-film having large kerr rotation angle and production process thereof.**

 A thin film having a large high Kerr rotation angle is formed of a compound having a composition represented by the following formula (I):

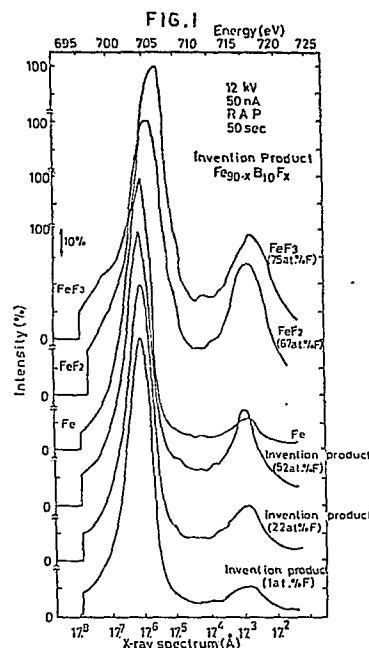


wherein

- J: at least one of F, Cl, Br and I;
 L: at least one of B, C, Al, Si, P, As, Sb, Bi, Se, Te, Ti, V, Cr, Mn, Ni, Ga, Ge, Zr, Nb and Mo;
 Q: at least one of Fe and Co;
 x: a value of 3 – 80; and
 y: a value satisfying the following equation (II):
 $3 \leq x + y \leq 80$

(II)

The film is produced by reacting a halogen or halogen-containing gas, which has occurred as a result of decomposition of a halogen compound, with a metal plasma or halogen-containing metal plasma and allowing the resultant compound to deposit as a thin film on a substrate.





DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.4)
X	US-A-3 572 894 (H. GUGGENHEIM et al.) * Claim 1; column 4, lines 41-68; column 5, lines 18-19 * ---	1,3	H 01 F 10/18 G 02 F 1/00 G 11 B 11/10
P,X	PATENT ABSTRACTS OF JAPAN, vol. 11, no. 288 (E-542)[2735], 17th September 1987; & JP-A-62 86 807 (RES. DEV. CORP. OF JAPAN) 21-04-1987 * Abstract * -----	1,3	
			TECHNICAL FIELDS SEARCHED (Int. Cl.4)
			H 01 F G 02 F G 11 B
The present search report has been drawn up for all claims			
Place of search THE HAGUE		Date of completion of the search 17-08-1989	Examiner VITZTHUM N.A.
CATEGORY OF CITED DOCUMENTS			
X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document		T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document	